

# Initial results for reactivity of lithium films on a molybdenum substrate

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Bob Kaita, PPPL

LRTSG,  
PPPL

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# Need for benchmark data on fundamental surface physics of Li

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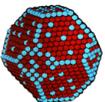
- Density control will be important for optimizing and controlling high non-inductive current-drive fraction scenarios in NSTX-U.
- Lithium conditioning of PFCs has been shown to pump hydrogenic species however contamination by residual gases is believed to limit its performance.
- A quantitative understanding of the influence of residual gases on lithium adsorption of deuterium by lithium will facilitate predictions of particle control in NSTX-U.

## Opportunity:

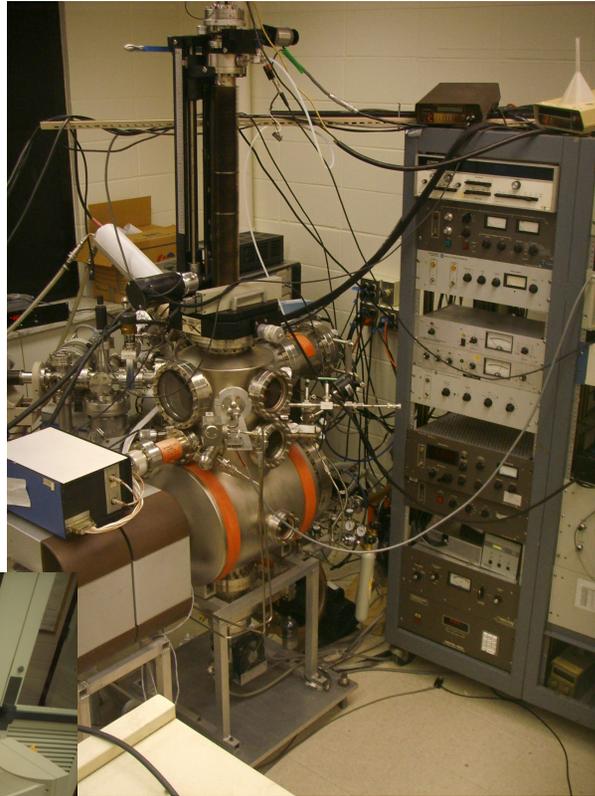
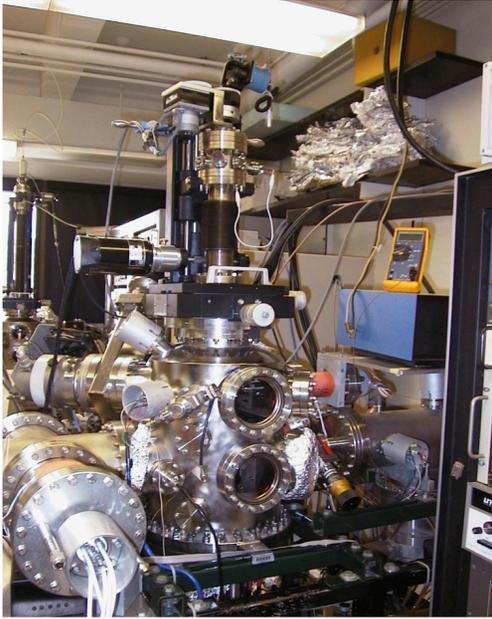
Fundamental data on plasma- Li-PFC interactions will lay the groundwork, and reduce the risk for innovative PFCs in NSTX-U.

Minimizing advanced Li-PFC risk is also critical for NSTX-U's missions in other ST areas.

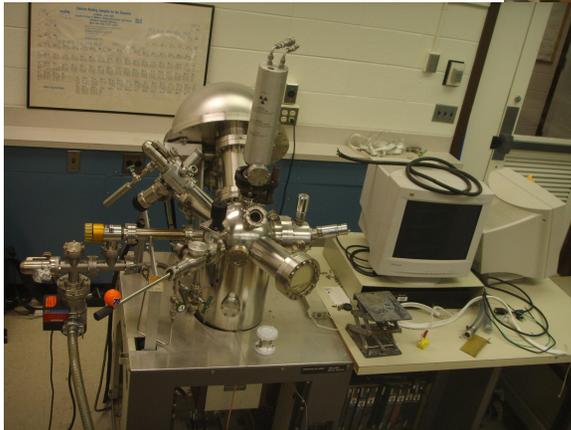
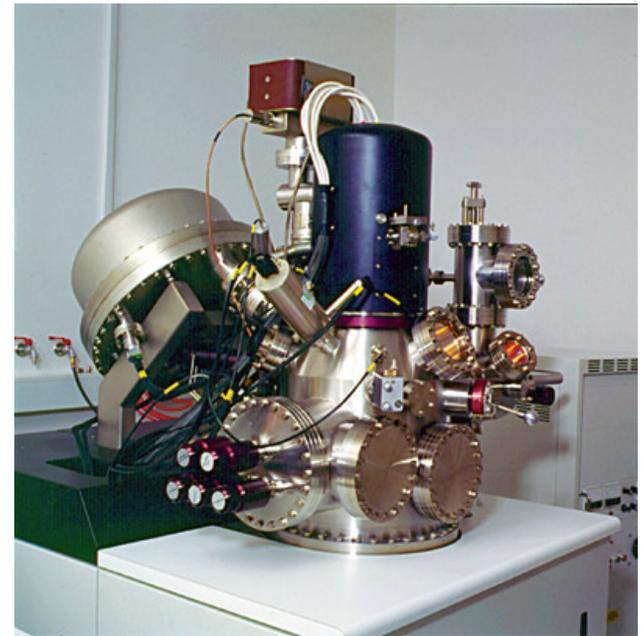
(C. Skinner)



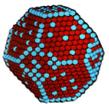
# New materials characterization labs at PPPL



**C123**



**T260**



# Initial studies to assist with quantitative projections for pumping and D recycling by Li coatings

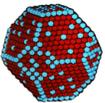
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- X-ray Photoelectron Spectroscopy (XPS) of gas reactions with solid Li
  - Uptake kinetics and reaction rates
  - Surface reaction products and compound formation
- Temperature Programmed Desorption (TPD) studies of Li films on Mo
  - Thermal stability and wetting
  - Metal-metal and metal-oxide bonding energies
- Auger Electron Spectroscopy (AES) and TPD studies of gas reactions with Li films on Mo
  - Thermal stability and wetting
  - Reaction pathways and decomposition products

“Plasma Facing Surface Composition During NSTX Li Experiments”, **C.H. Skinner**, R. Sullenberger, B.E. Koel, M. Jaworski, H.W. Kugel, *20<sup>th</sup> International Conference on Plasma Surface Interactions in Controlled Fusion Devices*, Aachen, Germany, May 2012

“Plasma facing surface composition during Li evaporation on NSTX and LTX”, **C.H. Skinner**, R. Majeski and B.E. Koel, *2<sup>nd</sup> International Symposium on Lithium Applications for Fusion Devices*, Princeton, NJ, April 2011

“Plasma facing surface composition during Li evaporation on NSTX and LTX”, **C. H. Skinner**, H.W. Kugel, R. Majeski, R. Kaita, R. Sullenberger, V. Surla and B.E. Koel, *53<sup>rd</sup> Annual Meeting of the APS Division of Plasma Physics*, Salt Lake City, Utah, November 2011

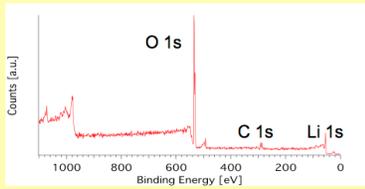


# XPS studies of gas reactions with solid Li

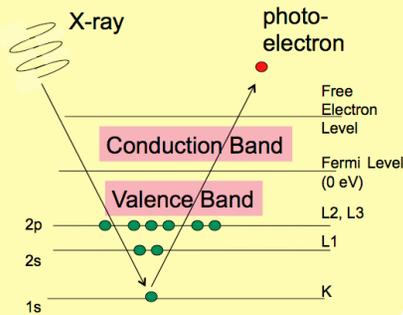
## Li surface oxidation tracked by X-ray photoelectron spectroscopy

Monochromatic Al  $K\alpha$  x-rays (1486.6 eV) photoionize atoms. Emitted photo-electron energies are measured with high resolution 300 mm radius hemispherical electrostatic analyzer. Photo-electron energy reveals chemical state of top  $\sim 20$  monolayers

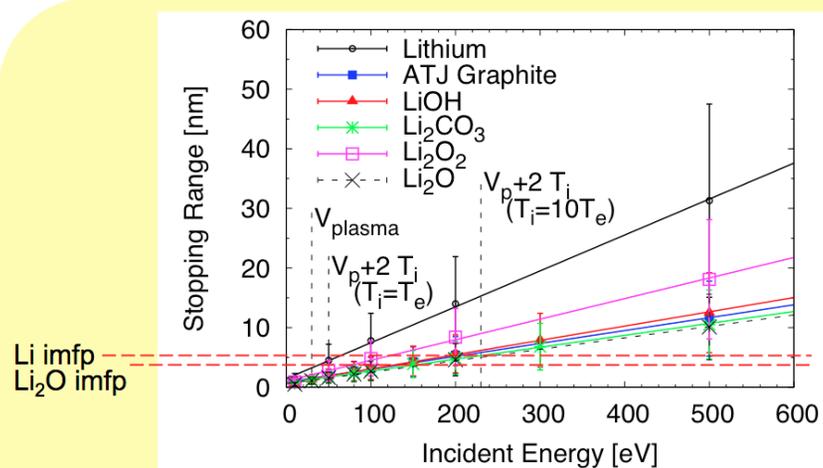
Electron Binding Energy = X-ray energy - Electron Kinetic Energy  
 $BE = h\nu - KE$



Broad scan XPS spectrum before gas exposure.



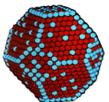
## XPS photoelectron range similar to D stopping range



TRIM calculations  
M. Jaworski

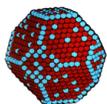
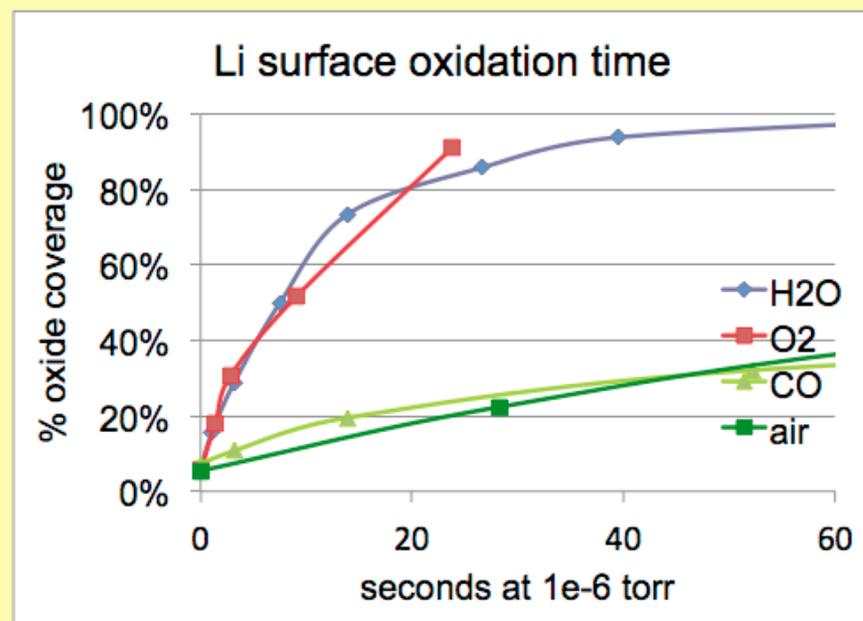
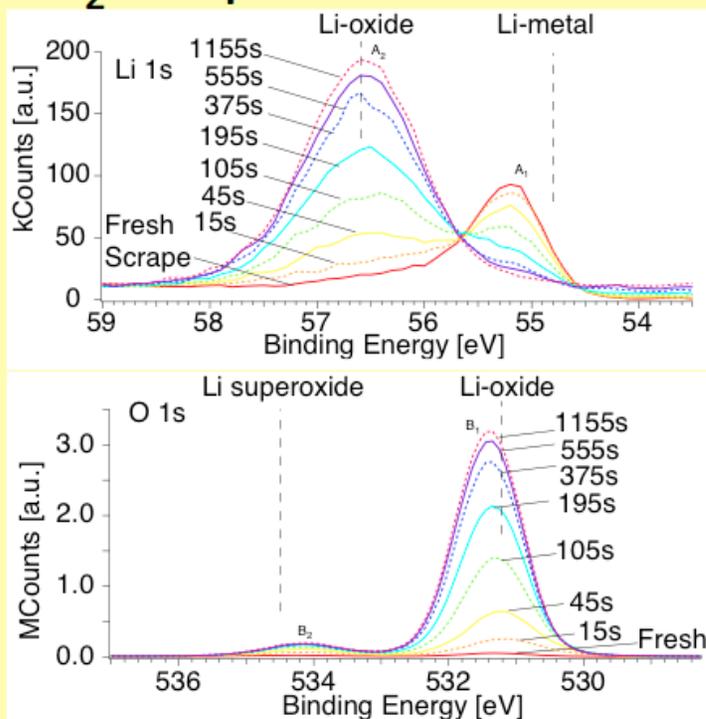
Li imfp  
Li<sub>2</sub>O imfp

Inelastic mean free path of XPS photoelectron  
in Li = 5.36 nm, in Li<sub>2</sub>O = 3.47 nm



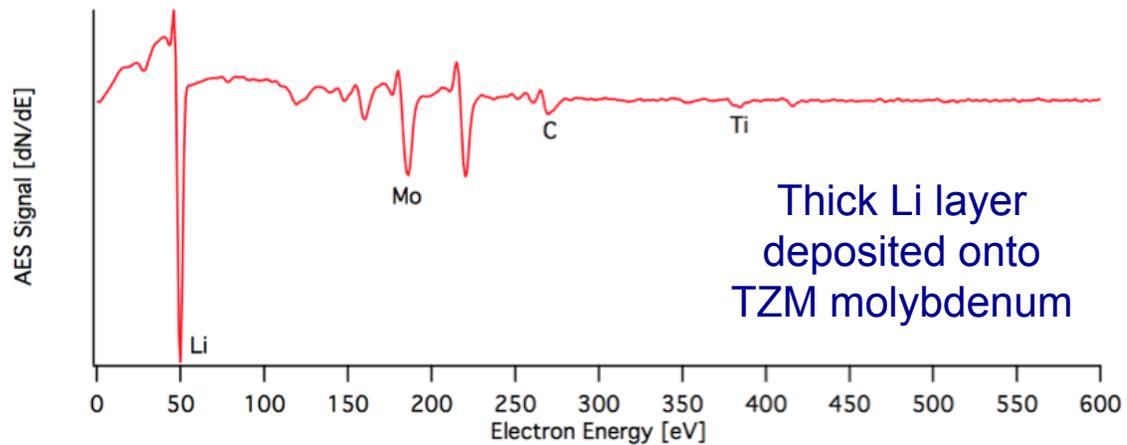
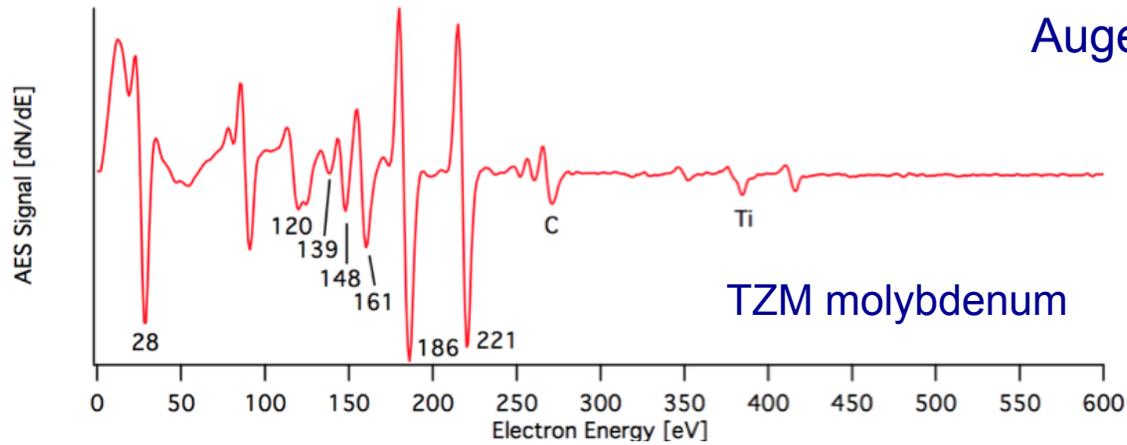
# Lithium oxide signal increases with H<sub>2</sub>O exposure time

## H<sub>2</sub>O exposure 6.2 e-8 Torr

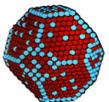
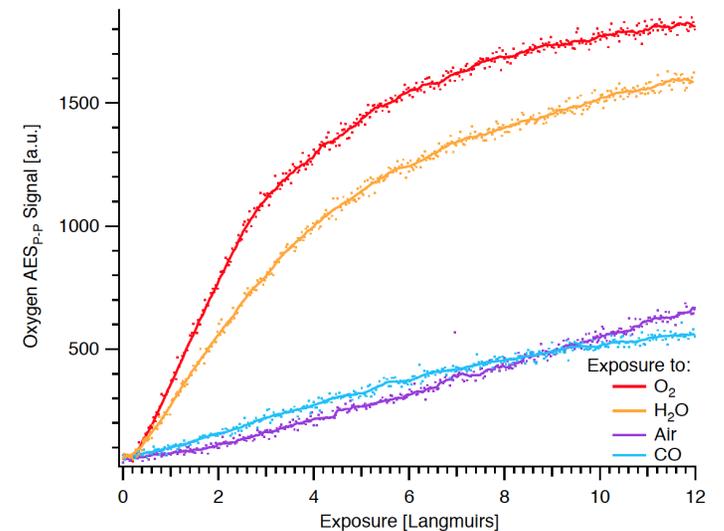


# AES studies of Li films on Mo

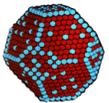
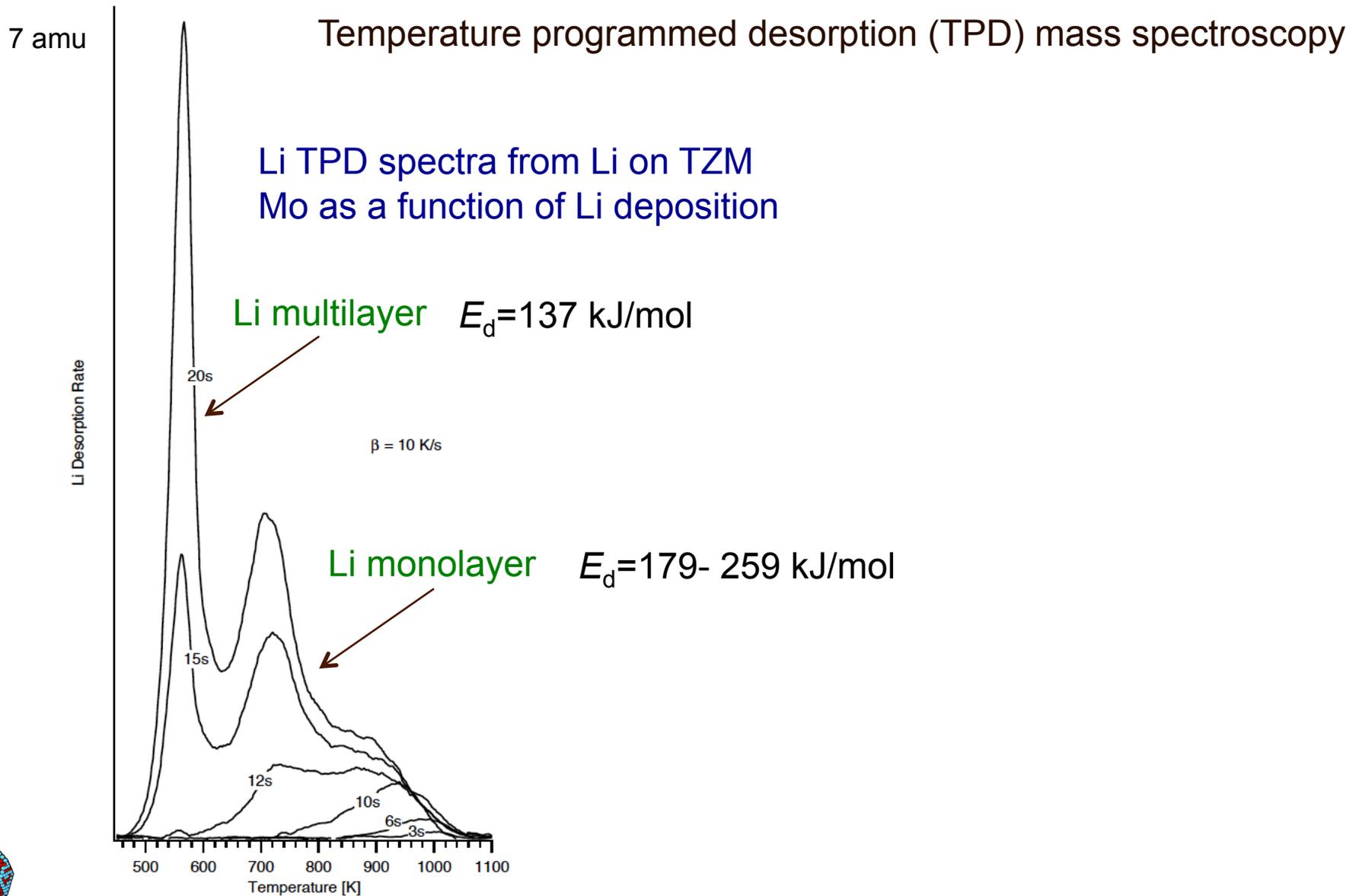
## Auger electron spectroscopy (AES)



## Oxidation of Li films on TZM molybdenum



# TPD studies of Li films on Mo



# Summary and Future Plans

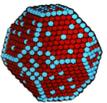
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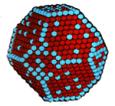
- A clean Li surface is oxidized to  $> 5$  nm depth in 20 s by  $10^{-6}$  torr of  $O_2$  or  $H_2O$ . Oxidation from CO is much slower.
- After a typical NSTX shot the  $H_2O$  partial pressure decreases from  $3 \times 10^{-6}$  torr –  $3 \times 10^{-8}$  torr with a corresponding oxidation time of 6 – 600 s.
- PFC surface after Li evaporation is a mixed material rather than a pure 'lithium coating'.
- Surface composition in flowing Li-PFC system will depend on base vacuum pressure and Li flow rate.

## Future Plans:

- Gas uptake kinetics and reaction rates on Li films, including effects of temperature, film thickness, and substrate type and preparation.
- Study effect of gas exposures on Li film thermal stability and wetting.
- Evaluate the thermal stability and decomposition mechanism of surface compounds formed from gas exposures
- Identify surface reaction products and compounds formed from gas exposures
- D atom, D ion, and D plasma sources to make D pumping measurements of clean and contaminated Li films on Mo

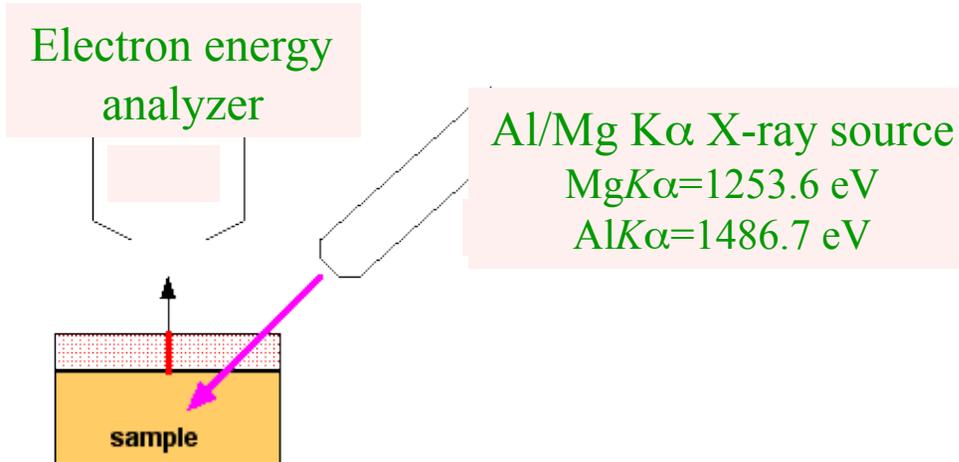
**Goal:** *D retention in Li vs. residual gas exposure, substrate temperature and fluence for incorporation in SOLPS model (Canik)*



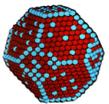
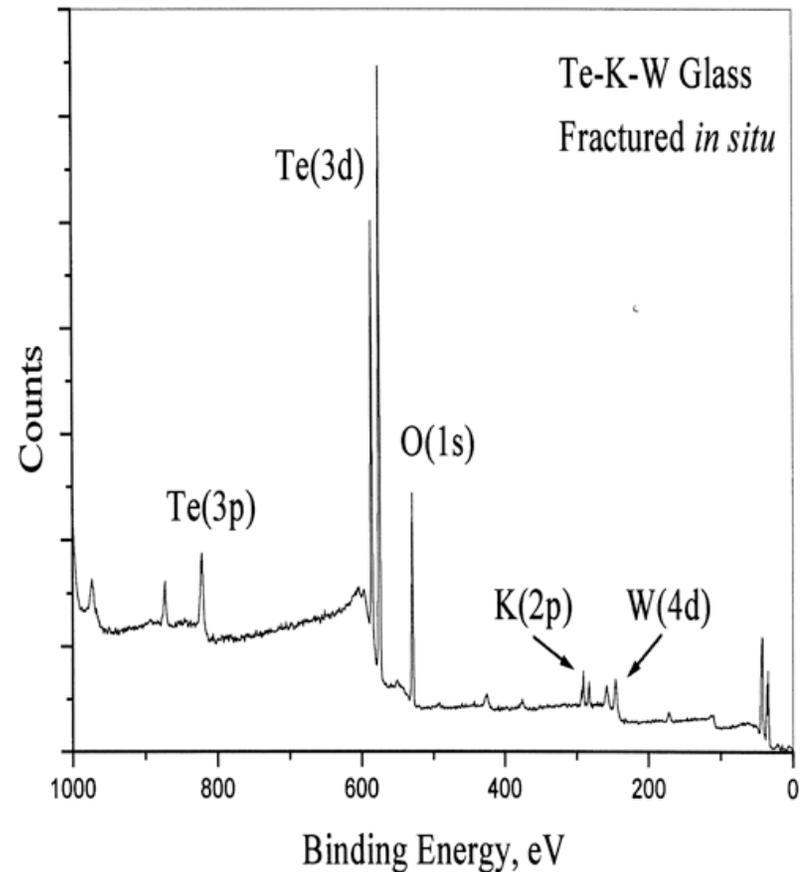
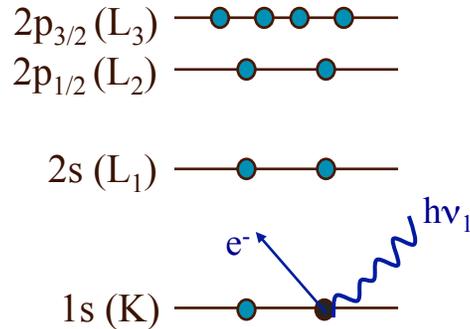


# XPS studies of gas reactions with solid Li

## X-ray Photoelectron Spectroscopy (XPS)\*



### Energy Levels

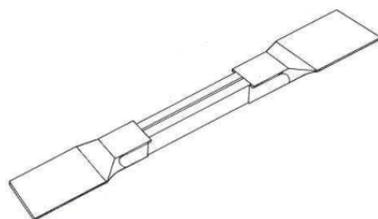


\*Electron Spectroscopy for Chemical Analysis (ESCA)

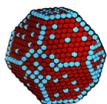
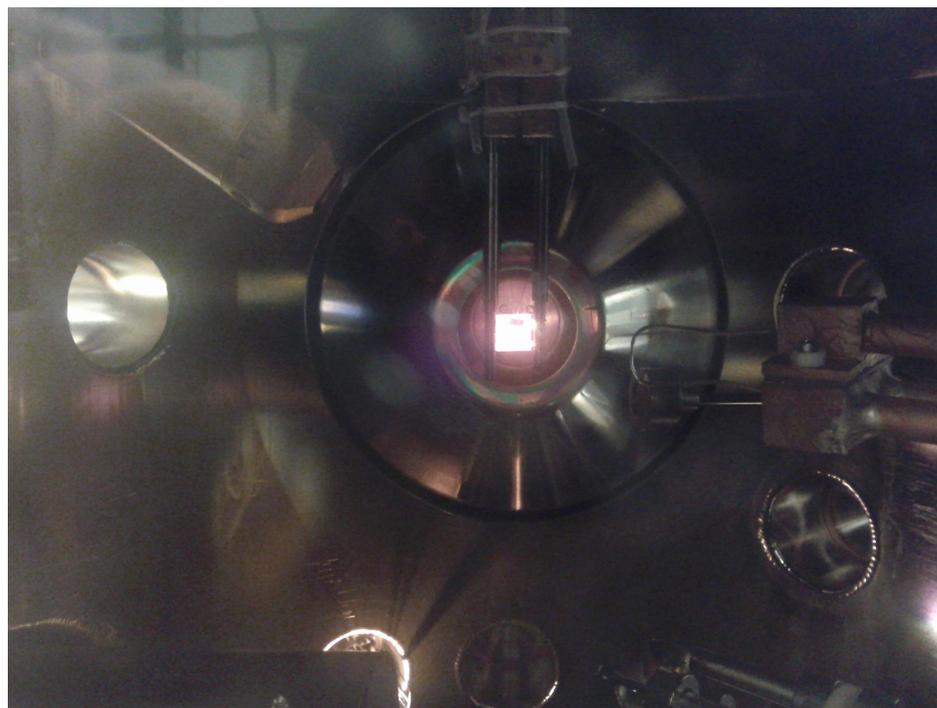
Princeton Surface Science

# AES and TPD studies of Li films on Mo

SAES Li getter source

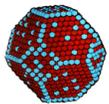
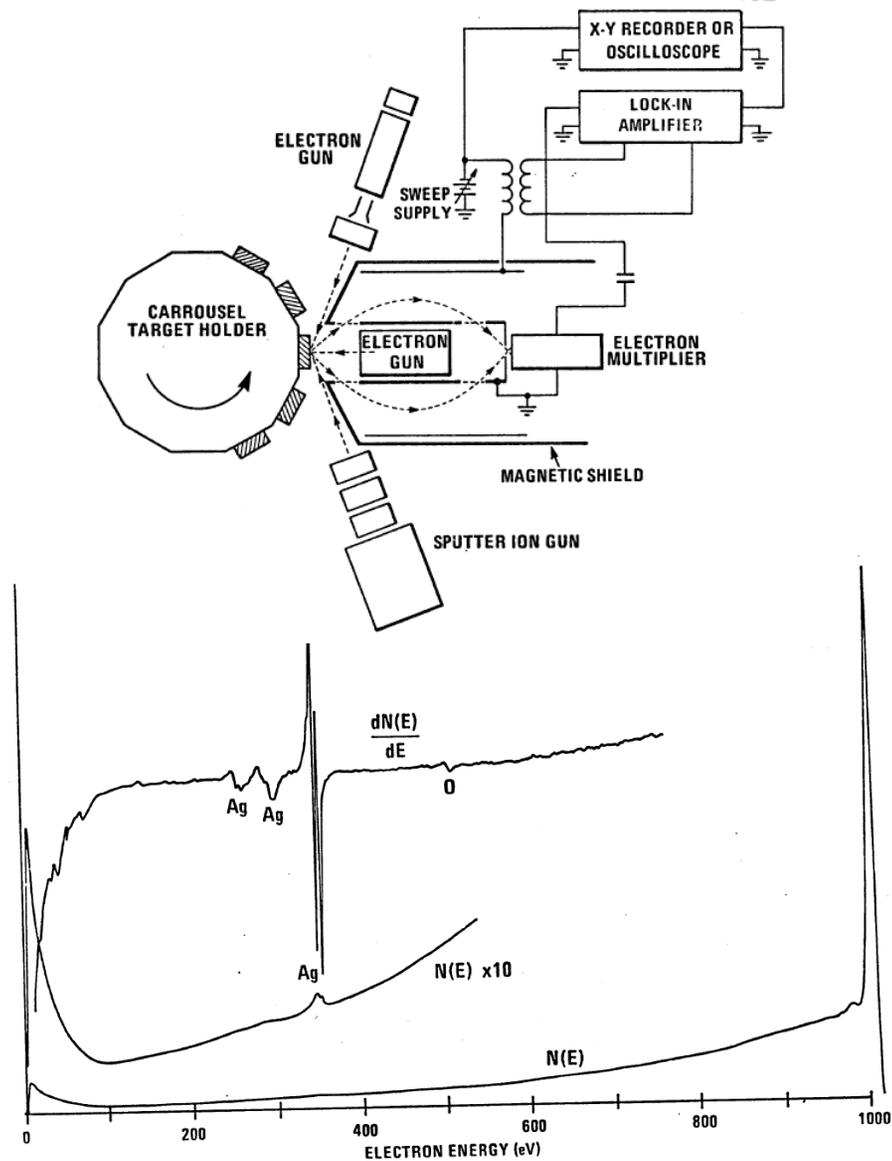
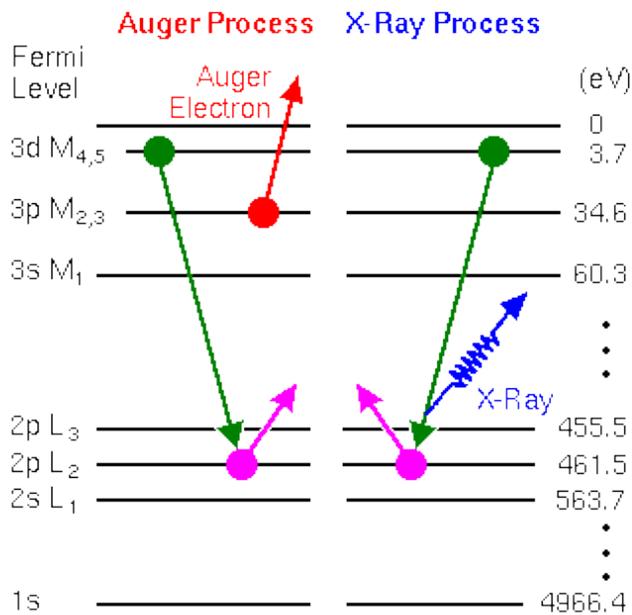


TZM Molybdenum sample



# AES and TPD studies of gas reactions with Li films on Mo

## Auger electron spectroscopy (AES)



# Temperature Programmed Desorption (TPD)

$$r_d = d\theta/dt = k_d \theta^n = \nu_n \exp(-E_d/RT) \theta^n$$

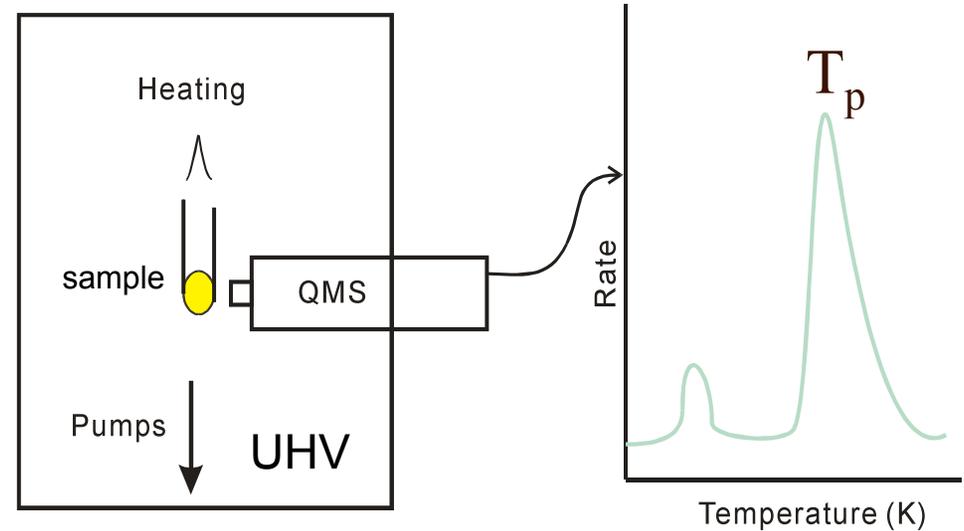
$E_d$  = desorption activation energy

A surface is heated and a mass spectrometer is used to measure the products desorbing from the surface. In a dynamically pumped system, the pressure is proportional to the desorption rate.

Information from TPD:

- reaction products & coverages
- reaction pathways
- desorption activation energies
- distribution of binding sites

Heating rate,  $\beta = dT/dt$



$$\frac{E_d}{RT_p^2} = \frac{\nu}{\beta} \exp\left(\frac{E_d}{RT_p}\right)$$

